Electronic Supplementary Material (ESI) for Journal of Materials Chemistry C. This journal is © The Royal Society of Chemistry 2018

## **Supplementary information**

PPy/Cu<sub>2</sub>O molecular imprinting composite film based visible light-

responsive photoelectrochemical sensor for microcystin-LR

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Fig. S1. (A) Effect of the concentration of pyrrole monomer on the photocurrent response. (B) Photocurrent responses of the PEC sensor fabricated using different proportions of monomers to template molecules. (from A to E: 10:0, 10:0.01, 10:0.4, 10:0.7, 10:1.4).

The photocurrent values of the PEC sensors were extensively affected by the concentration of pyrrole. As shown in Fig. S1A, the results indicated that the photocurrent value increased with the concentration of pyrrole and reached the maximum value about 87  $\mu$ A·cm<sup>-2</sup> when the pyrrole concentration was 0.01 mmol·L<sup>-1</sup>. However, the concentration of pyrrole was enlarged further, the photocurrent value decreased. So the concentration of pyrrole equal to 0.01 mmol·L<sup>-1</sup> was chosen for subsequent experiments. The performance of MIP was also affected by the molar ratio of monomers (pyrrole) to template molecules (MC-LR). In order to get the biggest photocurrent response of PEC sensor, MIP was synthesized using different

proportions of monomers and template molecules. Fig. S1B showed the photocurrent responses of MIP sensor in PBS buffer solution and PBS buffer solution containing 1.0  $\mu$ g·L MC-LR. It can be seen that the largest photocurrent response was obtained at the ratio of pyrrole to MC-LR equal to 10:0.7. Thus, the optimal experiment conditions were the phosphate-buffered solution (PBS) containing 0.1 mol·L-1 LiClO<sub>4</sub>, 700  $\mu$ g·L<sup>-1</sup> MC-LR as template molecules and 0.01 mmol·L<sup>-1</sup> pyrrole as functional monomers.



Fig. S2. Mapping images of individual atoms (A) Cu, (B) O, (C) C and (D) N on the MIP/Cu<sub>2</sub>O/ITO electrode surface.



Fig. S3 TG curves of MIP/Cu<sub>2</sub>O/ITO electrode.

The thermogravimetric analysis is applied to determine the content of PPy on MIP/Cu<sub>2</sub>O/ITO electrode, and the results are shown in Fig. S3. The first weight loss was about 1.34% between 25 - 210 °C which could be ascribed to the physically and chemically adsorbed water for MIP/Cu<sub>2</sub>O/ITO electrode measured in N<sub>2</sub> or air flow. The second weight loss between 210 - 650 °C was calculated as 1.50% for MIP/Cu<sub>2</sub>O/ITO electrode treated in N<sub>2</sub> stream, which might be attributed to the decomposition of PPy.<sup>1</sup> However, the weight loss of the second stage in air flow between 210 - 450 °C was about 1.14%, and reduced about 0.36% compared with that in N<sub>2</sub> flow, which might be due to the full oxidation of PPy and partially oxidation of Cu<sub>2</sub>O to CuO. Additionally, the third weight increment about 0.11% in air flow could be ascribed to the partially oxidation of Cu<sub>2</sub>O to CuO. According to the TG results, the PPy content of MIP/Cu<sub>2</sub>O/ITO electrode was 1.50%.



Fig. S4. (A) XPS survey spectrand high-resolution XPS spectra of (B) Cu 2p, (C) Cu LMM, (D) O 1s, (E) N 1s and (F) C 1s. (a to d: Cu<sub>2</sub>O/ITO, NIP/ Cu<sub>2</sub>O/ITO, MIP (with MC-LR)/Cu<sub>2</sub>O/ITO, MIP/Cu<sub>2</sub>O/ITO).



Fig. S5. Raman spectra of different electrode materials. (from a to d: Cu<sub>2</sub>O/ITO, NIP/Cu<sub>2</sub>O/ITO, MIP (with MC-LR)/Cu<sub>2</sub>O/ITO, MIP/Cu<sub>2</sub>O/ITO).

The Raman spectra of different modified electrode materials were shown in Fig. S4. All samples showed Raman shifts at 98, 144, 216, 308, 414, 521 and 629 cm<sup>-1</sup>, respectively. The strongest peak at 216 cm<sup>-1</sup> was assigned to the second-order Ramanallowed mode  $2\Gamma_{12}$  of the Cu<sub>2</sub>O crystals, which demonstrated the high structural quality of the synthesized samples.<sup>2</sup> The second intense Raman peak at 98 cm<sup>-1</sup> was attributed to the silence mode  $\Gamma_{25}^{-3}$  and the peak at 144 cm<sup>-1</sup> belonged to the infrared active mode of  $\Gamma_{15}$ <sup>-1.4</sup> Three relatively weak peaks at 414 cm<sup>-1</sup>, 521 cm<sup>-1</sup>, and 629 cm<sup>-1</sup> were assigned to four phonon mode (3  $\Gamma_{12}^{-+} \Gamma_{25}^{--}$ ), Raman-allowed mode  $\Gamma_{25}^{++}$ and red-allowed mode  $\Gamma_{15}^{(2)}$  in Cu<sub>2</sub>O, respectively.<sup>5</sup> In addition, the peak at 308 cm<sup>-1</sup> corresponded to the second-order overtone mode  $2\Gamma^{(1)}_{15-}$ .<sup>4</sup> The characteristic peaks of CuO under the same experimental conditions at 298, 330 and 602 cm<sup>-1</sup> could not be detected and therefore suggests that the Cu<sub>2</sub>O film is free of this contaminant.<sup>2</sup> After electropolymerization of PPy, all Raman peaks in the range of 50-700 cm<sup>-1</sup> almost didn't change.<sup>6</sup> However, from the b to d curves, PPy base bands were located at 1601 cm<sup>-1</sup> (C=C stretching in the pyrrole ring),<sup>7</sup> 1360 cm<sup>-1</sup> (ring-stretching mode of PPy),<sup>8</sup> 1262 cm<sup>-1</sup> (anti-symmetrical C-H in plane deformation), 1052 cm<sup>-1</sup> (symmetrical C-H in plane deformation), 912 cm<sup>-1</sup> (C-H out of the plane

deformation).<sup>9</sup> The peaks in the range of 800-1800 cm<sup>-1</sup> was very weak, which implied the amount of molecular imprinted PPy was low.



Fig. S6. FTIR spectra of different electrode materials. (from a to d: Cu<sub>2</sub>O/ITO, NIP/Cu<sub>2</sub>O/ITO, MIP/Cu<sub>2</sub>O/ITO, MIP/Cu<sub>2</sub>O/ITO).

The Fourier transform infrared (FTIR) spectra of different modified electrode materials were shown in Fig. S6. The intense absorption band at 609 cm<sup>-1</sup> was assigned to the characteristic Cu-O stretching vibration in the Cu<sub>2</sub>O phase.<sup>10</sup> The band at 1630 cm<sup>-1</sup> was respectively caused by bending vibration of surface O-H bond of adsorbed H<sub>2</sub>O. The peaks at 1550 cm<sup>-1</sup> and 1498 cm<sup>-1</sup> were correspond to the anti-symmetric and symmetric stretching vibration of C=C in pyrrole rings,<sup>11, 12</sup> while the peaks at 1338 cm<sup>-1</sup> were due to C-N stretching vibration of pyrrole rings. These results indicated that the PPy was formed successfully on the surface of Cu<sub>2</sub>O films. After the MIP modification with MC-LR, the characteristic peaks centered at 1647 cm<sup>-1</sup> and 1573 cm<sup>-1</sup> appeared which could be ascribed to bending vibration of -CO-NH-, and -N-H bonds, respectively.<sup>13</sup> The band at 1392 cm<sup>-1</sup> corresponded to the COO<sup>-</sup> asymmetric stretching vibration,<sup>14</sup> while the band at 1700 cm<sup>-1</sup> was attributed to C=O stretching vibration.<sup>15</sup> After removing the template molecule (MC-LR), the intensities of these three peaks decreased obviously, which implied the recognition sites for MC-LR were successfully constructed on the PPy films.



Scheme S1 Schematic diagram of MC-LR recognition mechanism

Table S1 Atomic percent of  $Cu_2O/ITO$ , NIP/ $Cu_2O/ITO$ , MIP (with MC-LR)/ $Cu_2O/ITO$ , MIP/ $Cu_2O/ITO$  electrodes

Samples	Atomic%				
	C1s	N1s	O1s	Cu 2p	
Cu <sub>2</sub> O/ITO	44.52	-	41.4	14.07	
NIP/Cu <sub>2</sub> O/ITO	37.32	1.03	49.33	15.92	
MIP (with MC-LR)/Cu <sub>2</sub> O/ITO	48.50	1.36	40.08	10.07	
MIP/Cu <sub>2</sub> O/ITO	40.77	0.69	45.78	12.76	

Methods	Analytical range	LOD	Ref.
Fluorescent aptasensor	0.4 - 1200 nM	138 pM	16
Electrochemical immunosensor	$0.0025 - 5 \text{ ug} \cdot \text{L}^{-1}$	1.68 ng∙L <sup>-1</sup>	17
ECL biosensor	0.1 <b>-</b> 1000 pM	0.03 pM	18
~			10
Colorimetric detection	0.1 - 250 nM	0.05 nM	19
01 11		0.000 1.1	20
Chemiluminescence immunoassay	0.02 - 200 μg·L <sup>-1</sup>	$0.006 \text{ ug} \cdot \text{L}^{-1}$	20
This work	0.001 10 ug·I -1	$0.23 \text{ ng} \cdot \text{I}^{-1}$	
THIS WOLK	0.001 - 10 μg·L ·	0.23 llg*L *	

Table S2. Comparison of the present and other reported methods for the MC-LR detection.

Table S3. Comparison of the present and other PEC sensors for the MC-LR detection.

Materials and method	Analytical range	LOD	Re
	Analytical lange	LOD	
MIP@TiO <sub>2</sub> NTs	0.5 - 100 μg·L <sup>-1</sup>	0.1 μg·L <sup>-1</sup>	21
CdS/graphene immunoassay	0.01 - 25 μg·L <sup>-1</sup>	$0.010 \ \mu g \cdot L^{-1}$	22
GQD/silicon NW immunosensor	0.1 - 10 μg·L <sup>-1</sup>	$0.055 \ \mu g^{-1}$	23
BiOBr nanoflakes/N-GR aptasensor	1.0 pM - 100 nM	0.03 pM	24
GR@TiO <sub>2</sub> NTs aptasensor	1.0 - 500 fM	0.5 fM	25
MI-TiO <sub>2</sub> @CNTs	1.0 pM - 3.0 nM	0.4 pM	26
CdS/TiO <sub>2</sub> NRAs-Fe <sub>3</sub> O <sub>4</sub> @PDA immunosensor	0.005 - 500 μg·L <sup>-1</sup>	0.001µg·L <sup>-1</sup>	27
CdS/B-TiO <sub>2</sub> immunosensor	0.001 - 100 μg·L <sup>-1</sup>	0.7 ng·L <sup>-1</sup>	28
This work	0.001 - 10 μg·L <sup>-1</sup>	0.23 ng·L <sup>-1</sup>	

## Reference

- J. Chen, C. Shu, N. Wang, J. Feng, H. Ma and W. Yan, J. Colloid Interf. Sci., 2017, 495, 44-52.
- S. Shyamal, P. Hajra, H. Mandal, J. K. Singh, A. K. Satpati, S. Pande and C. Bhattacharya, ACS Appl. Mater. Interfaces, 2015, 7, 18344-18352.
- H. Zhang, D. Zhang, L. Guo, R. Zhang, P. Yin and R. Wang, J. Nanosci. Nanotechnol., 2008, 8, 6332-6337.
- 4. Y. Mao, J. He, X. Sun, W. Li, X. Lu, J. Gan, Z. Liu, Li Gongb, J. Chen, P. Liu and Y. Tong, *Electrochim. Acta*, 2012, **62**, 1-7.
- 5. P. Wang, Y. H. Ng and R. Amal, *Nanoscale*, 2013, **5**, 2952-2958.
- 6. E. Kecsenovity, B. Endrődi, P. S. Tóth, Y. Zou, R. A. W. Dryfe, K. Rajeshwar and C. Janáky, *J. Am. Chem. Soc.*, 2017, **139**, 6682-6692.
- J. Kopecká, M. Mrlík, R. Olejník, D. Kopecký, M. Vrňata, J. Prokeš, P. Bober,
  Z. Morávková, M. Trchová and J. Stejskal, *Sensors*, 2016, 16, 1917.
- 8. G. Han and G. Shi, J. Appl. Polym. Sci., 2007, 103, 1490-1494.
- I. Chikouche, A. Sahari, A. Zouaoui and S. Tingry, *Can. J. Chem. Eng.*, 2015, 93, 1076-1080.
- G. Papadimitropoulos, N. Vourdas, V. E. Vamvakas and D. Davazoglou, *Thin Solid Films*, 2006, 515, 2428-2432.
- 11. Z. Fan, J. Zhu, X. Sun, Z. Cheng, Y. Liu and Y. Wang, ACS Appl. Mater. Interfaces, 2017, 9, 21763-21772.
- 12. J. Jun, J. S. Lee, D. H. Shin, J. Oh, W. Kim, W. Na and J. Jang, *J. Mater. Chem. A*, 2017, **5**, 17335–17340.
- S.-D. Pan, X.-H. Chen, X.-P. Li, M.-Q. Cai, H.-Y. Shen, Y.-G. Zhao and M.-C. Jin, *J. Mater. Chem. A*, 2015, **3**, 23042–23052.
- Y. Chen, X. Zhang, Q. Liu, X. Wang, L. Xu and Z. Zhang, J. Hazard. Mater., 2015, 299, 325-332.
- W. Teng, Z. Wu, J. Fan, W.-x. Zhang and D. Zhao, *J. Mater. Chem. A*, 2015, 3, 19168–19176.
- S. M. Taghdisi, N. M. Danesh, M. Ramezani, N. Ghows, S. A. Mousavi Shaegh and K. Abnous, *Talanta*, 2017, 166, 187 - 192.

- J. Zhang, Y. Sun, H. Dong, X. Zhang, W. Wang and Z. Chen, Sensor. Actuat. B-Chem., 2016, 233, 624 - 632.
- X. Du, D. Jiang, N. Hao, J. Qian, L. Dai, L. Zhou, J. Hu and K. Wang, *Anal. Chem.*, 2016, 88, 9622-9629.
- F. Wang, S. Liu, M. Lin, X. Chen, S. Lin, X. Du, H. Li, H. Ye, B. Qiu, Z. Lin, L. Guo and G. Chen, *Biosen. Bioelectron.*, 2015, 68, 475 - 480.
- 20. J. Lu, W. Wei, L. Yin, Y. Pu and S. Liu, *Analyst*, 2013, **138**, 1483-1489.
- K. Chen, M. Liu, G. Zhao, H. Shi, L. Fan and S. Zhao, *Environ. Sci. Technol.*, 2012, 46, 11955-11961.
- 22. J. Tian, H. Zhao, H. Zhao and X. Quan, *Microchim. Acta*, 2012, **179**, 163 170.
- J. Tian, H. Zhao, X. Quan, Y. Zhang, H. Yu and S. Chen, Sensor. Actuat. B-Chem., 2014, 196, 532-538.
- X. Du, D. Jiang, L. Dai, L. Zhou, N. Hao, J. Qian, B. Qiu and K. Wang, Biosen. Bioelectron., 2016, 81, 242-248.
- 25. M. Liu, J. Yu, X. Ding and G. Zhao, *Electroanalysis*, 2016, 28, 161-168.
- M. Liu, X. Ding, Q. Yang, Y. Wang, G. Zhao and N. Yang, *J. Hazard. Mater.*, 2017, **331**, 309-320.
- J. Wei, A. Qileng, Y. Yan, H. Lei, S. Zhang, W. Liu and Y. Liu, *Anal. Chim. Acta*, 2017, **994**, 82-91.
- A. Qileng, Y. Cai, J. Wei, H. Lei, W. Liu, S. Zhang and Y. Liu, Sensor. Actuat. B-Chem., 2018, 254, 727-735.